

Optical Pumping

David Cheney

Electrical & Computing Engineering

MURI Review May 2010

G A T O R
Engineering



UNIVERSITY OF
FLORIDA

Overview

- Introduction/Background
 - Optical Pumping
 - Mercury Arc Light
- Tests and Data
 - Proof-of-concept
 - To Failure
 - AFRL parts
- Future Work

INTRODUCTION

- Limitations of high temperature accelerated testing
- Understanding non-temperature acceleration factors
- More realistic MTTF

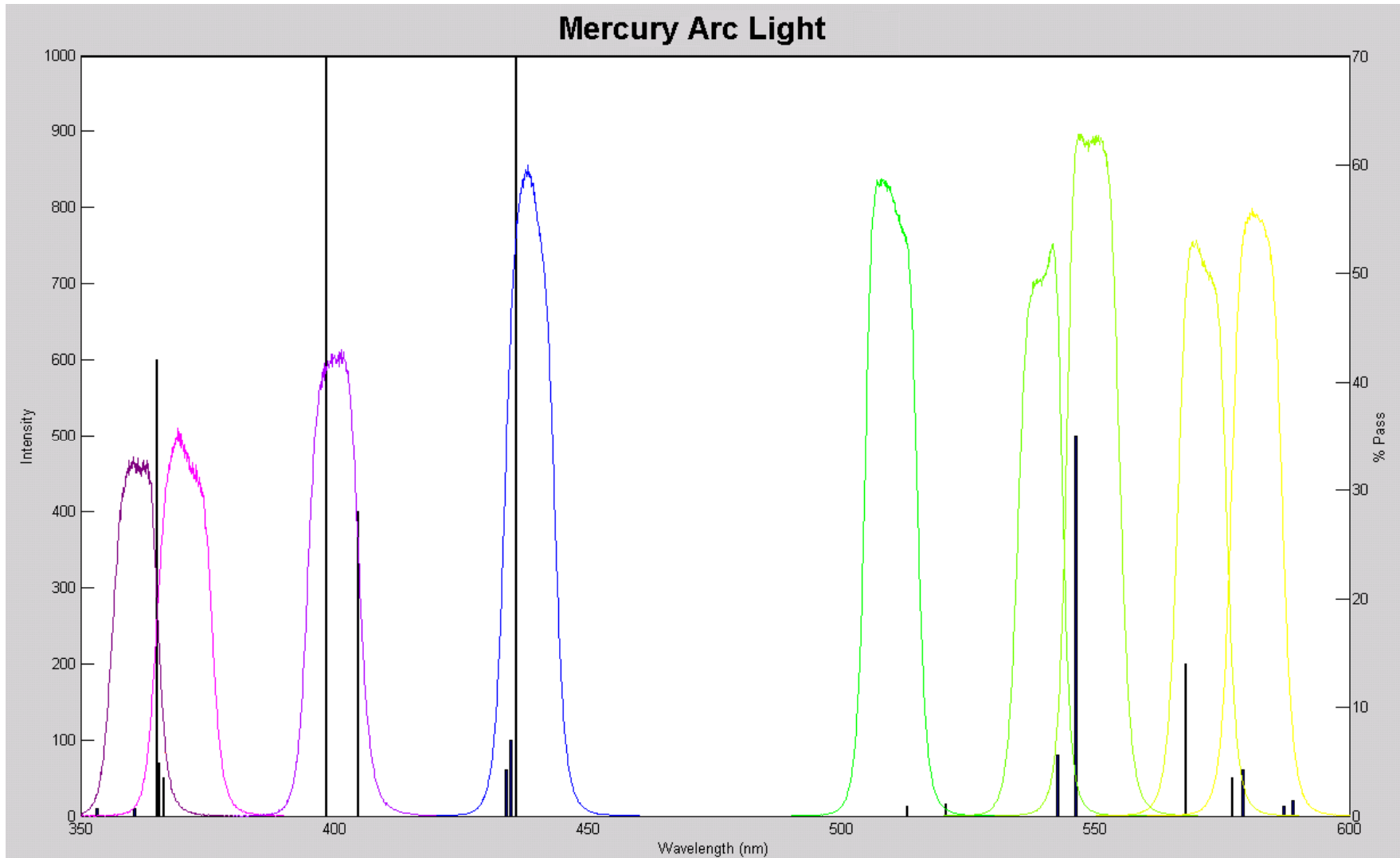
BACKGROUND

- Accelerate aging by optically pumping a GaN HEMT under DC bias stress
- Unfiltered mercury arc light source
 - Pumps above-band-gap energy into the device
 - Emptying all the traps within the band-gap
 - Exciting electrons into the conduction band
- Filtered Light
 - Below band-gap to target specific traps

BACKGROUND

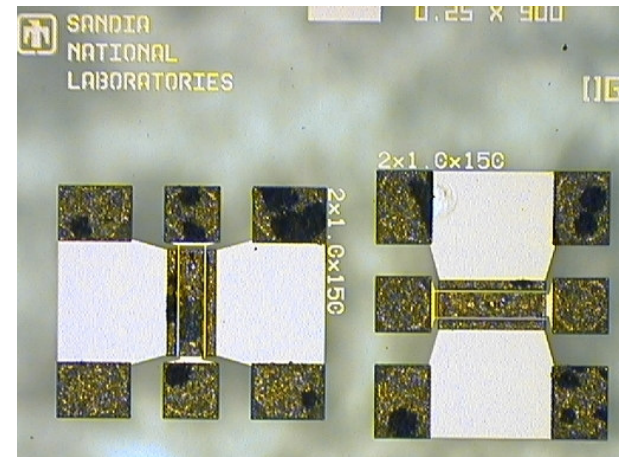
- Optical pumping results in increased I_D
 - Excited electrons from the valence band
 - Emptied traps
- Increased I_D
 - Test the effects of drain currents under lower drain-source fields
 - Reach higher power levels with lower gate-drain fields
 - Targets the device's channel

BACKGROUND

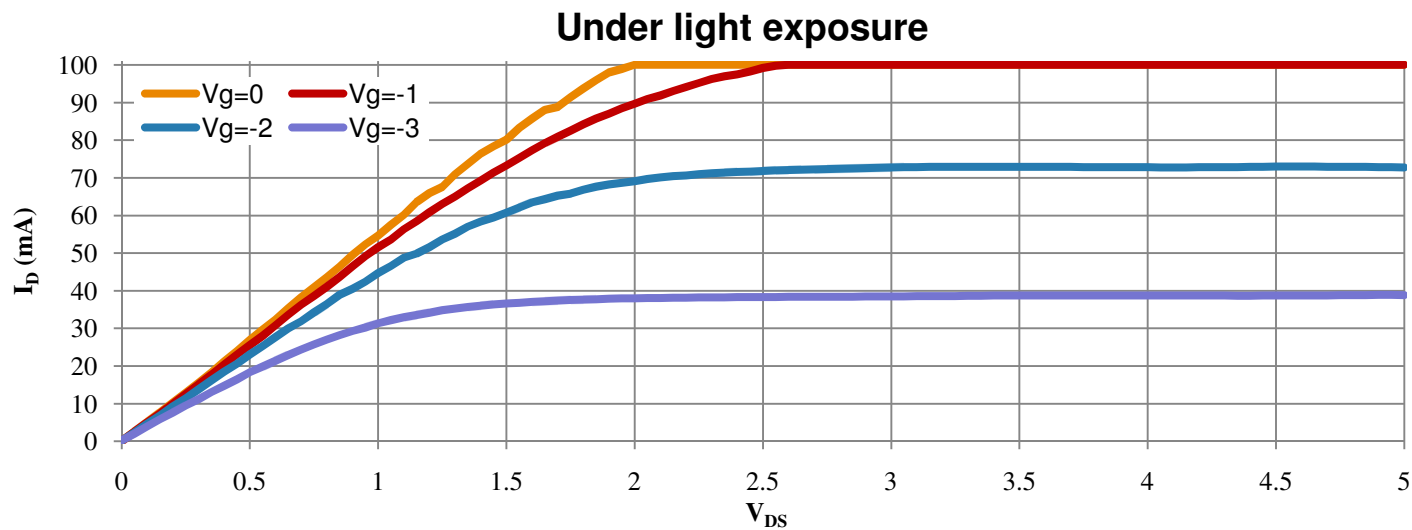
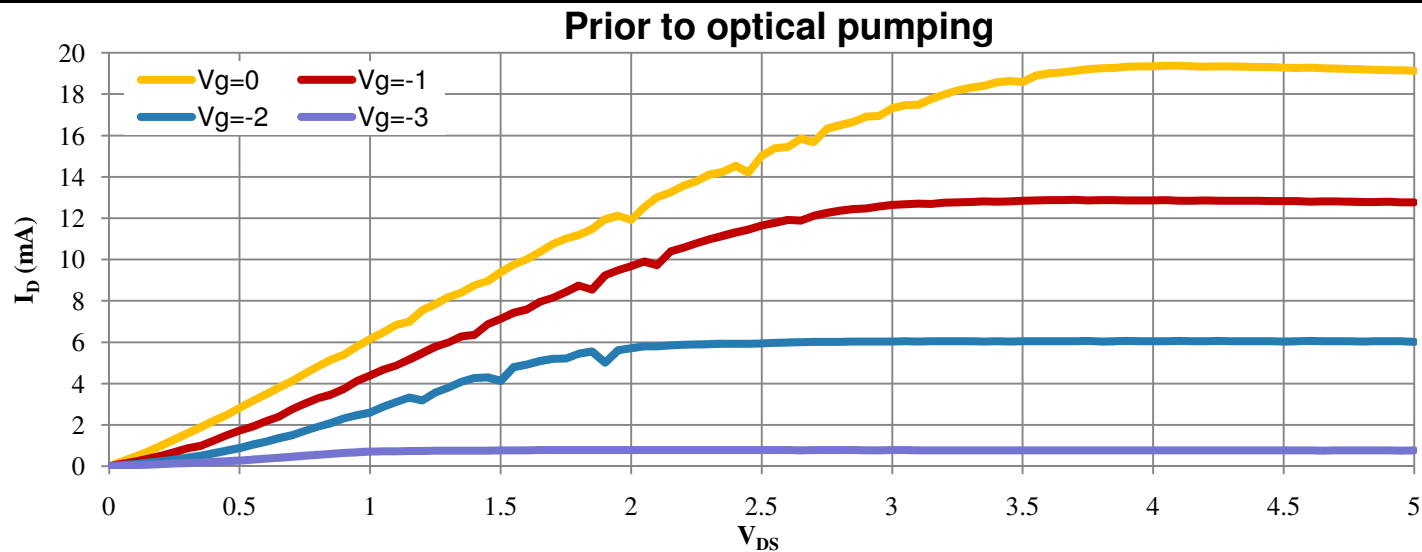


PROOF-OF-CONCEPT

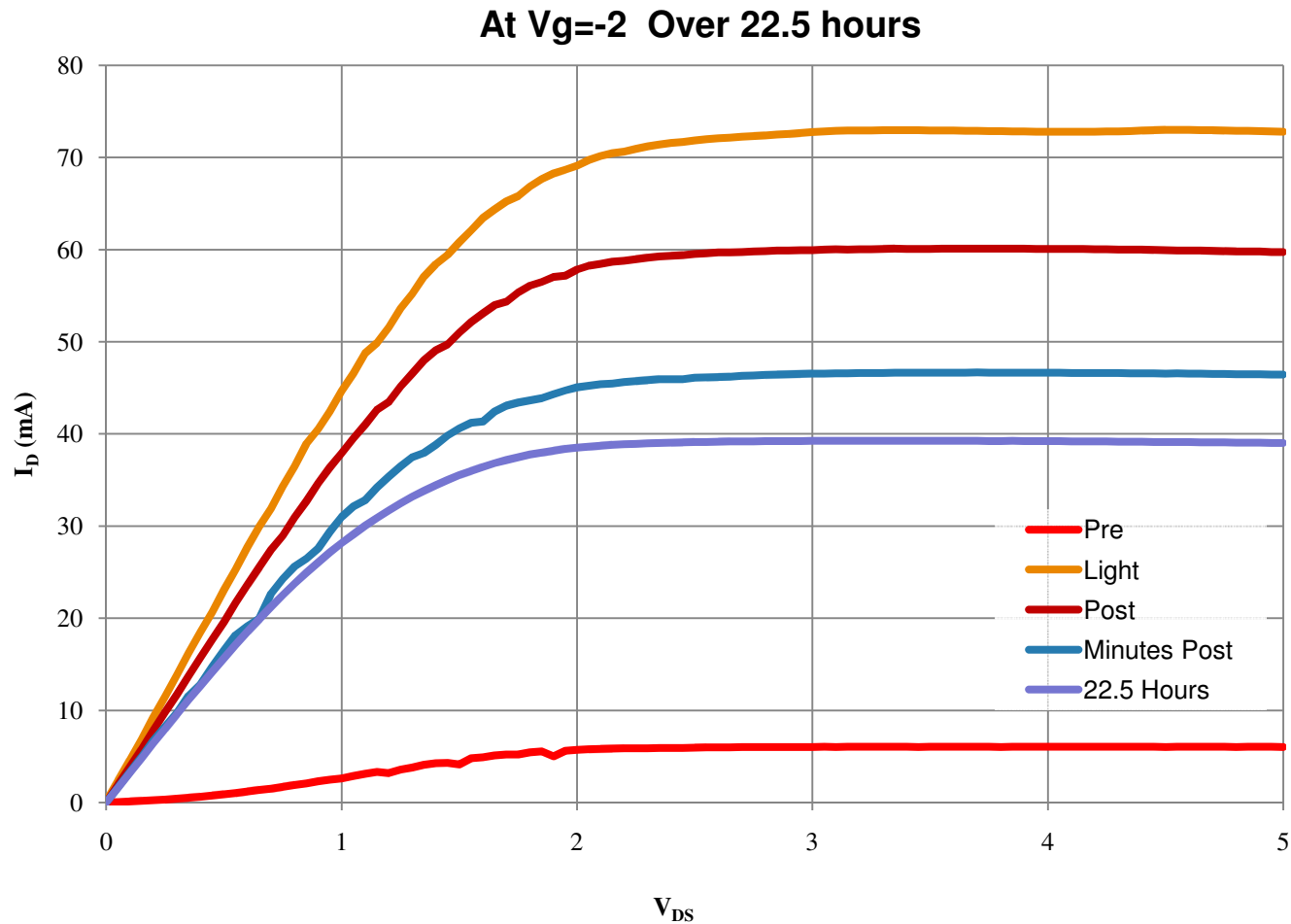
- Probe station and programmable curve tracer
- Proof of concept test
 - Optically pump device
 - Measure device performance while and after exposing
- Compare to unexposed devices
- Device
 - 2003 Vintage GaN HEMT from Sandia Labs
 - Dual gate 0.75 x 100 micron



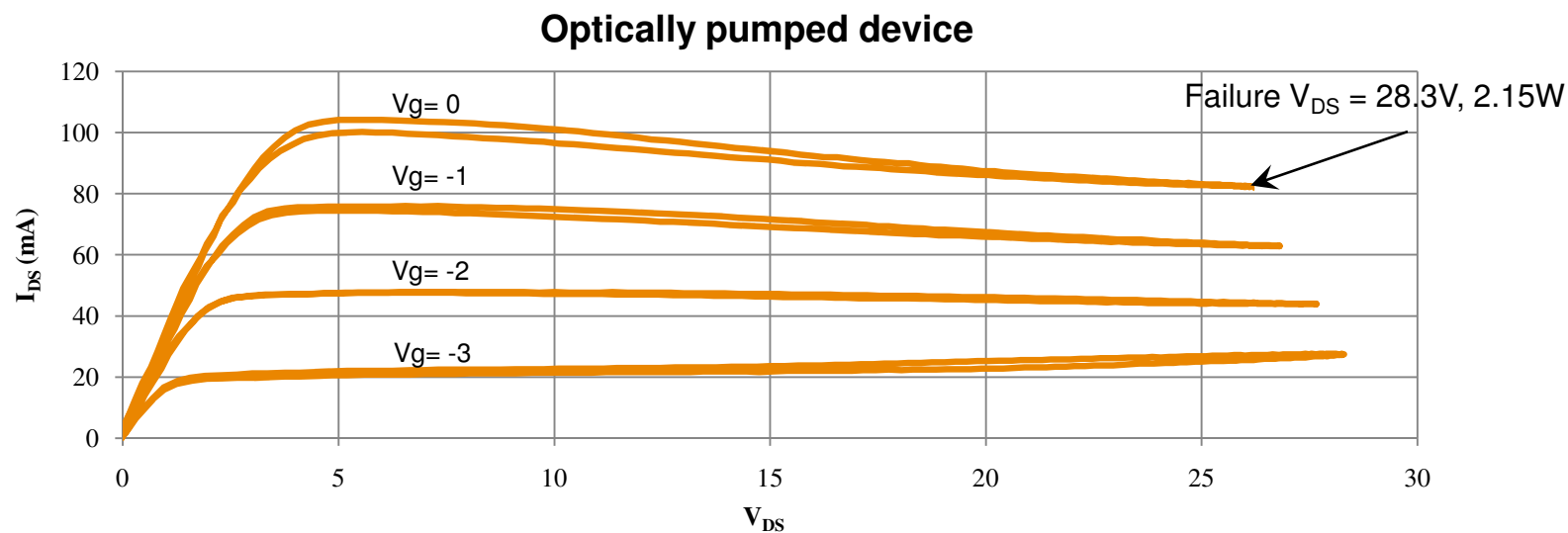
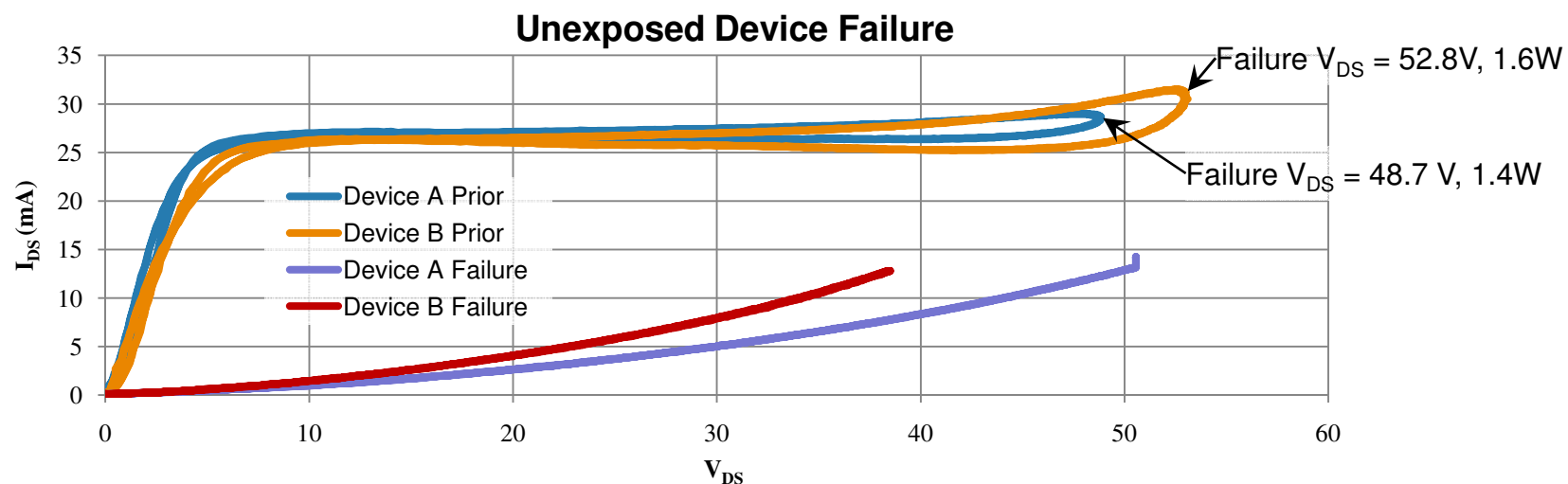
PROOF-OF-CONCEPT RESULTS



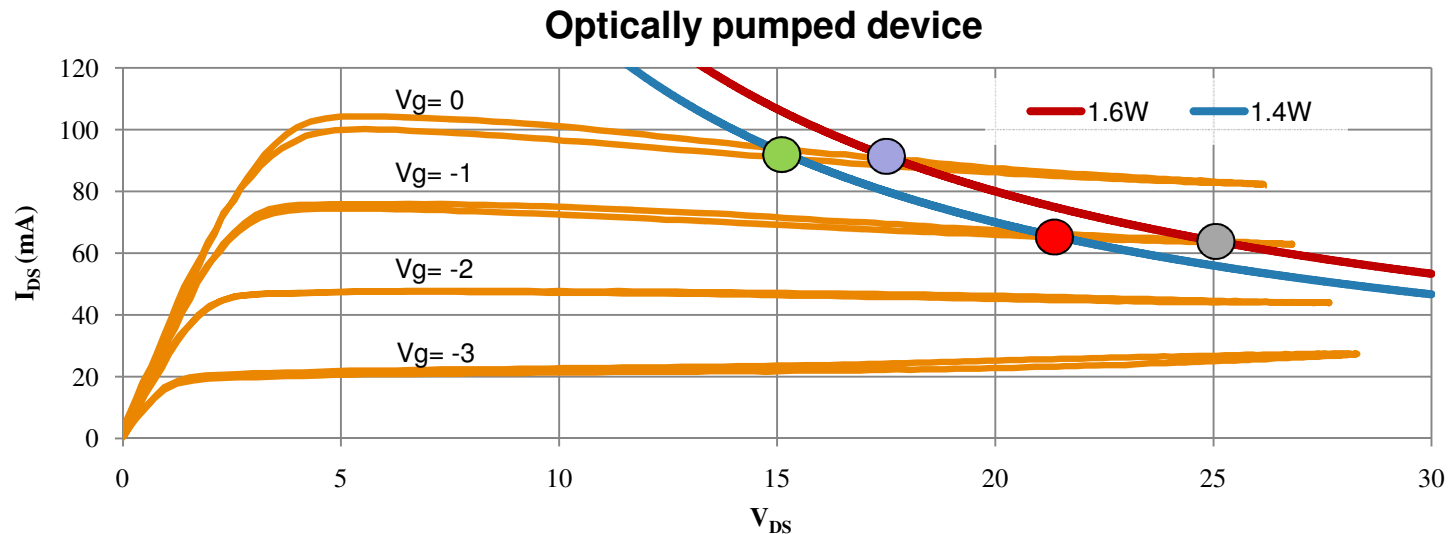
RESULTS – OPTICAL PUMPING



TO FAILURE - RESULTS



FAILURE RESULTS – COMPARISON



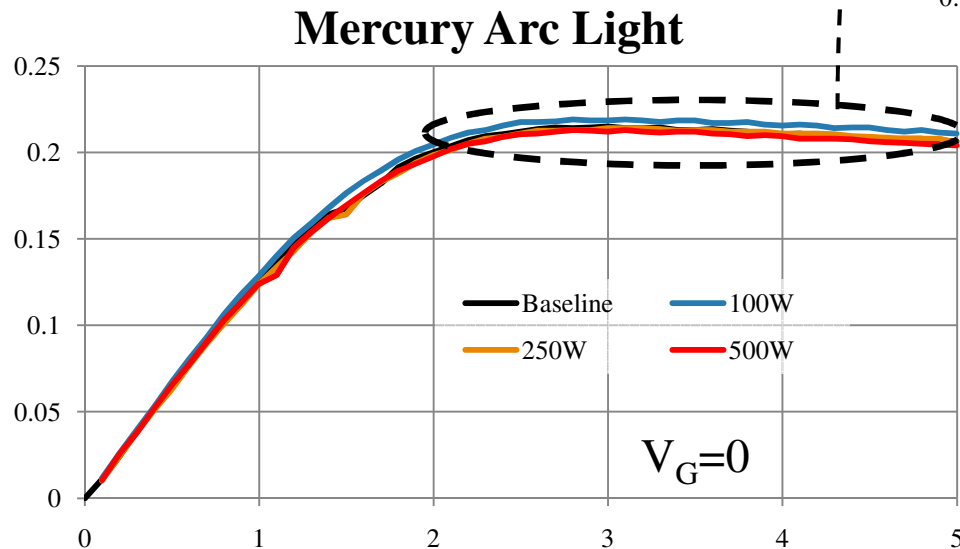
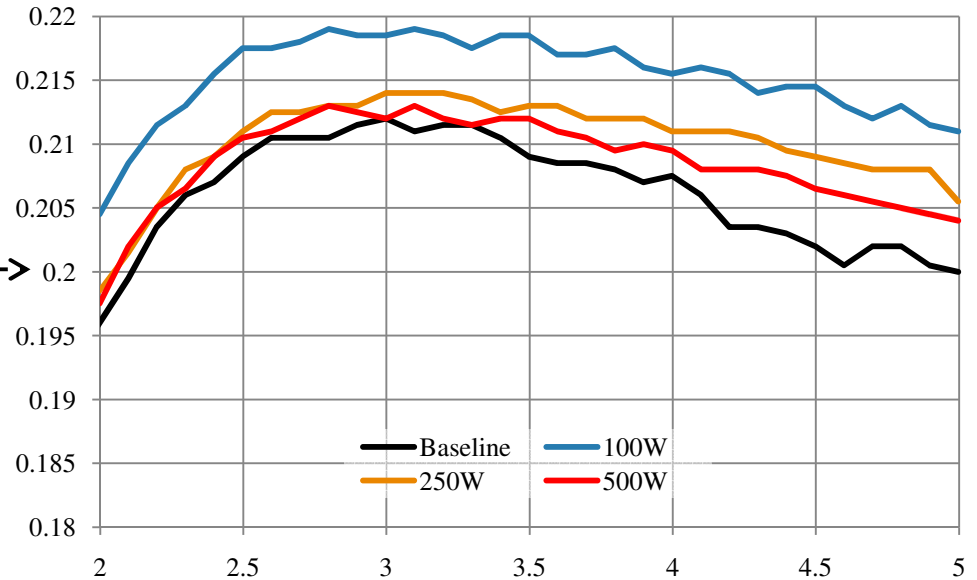
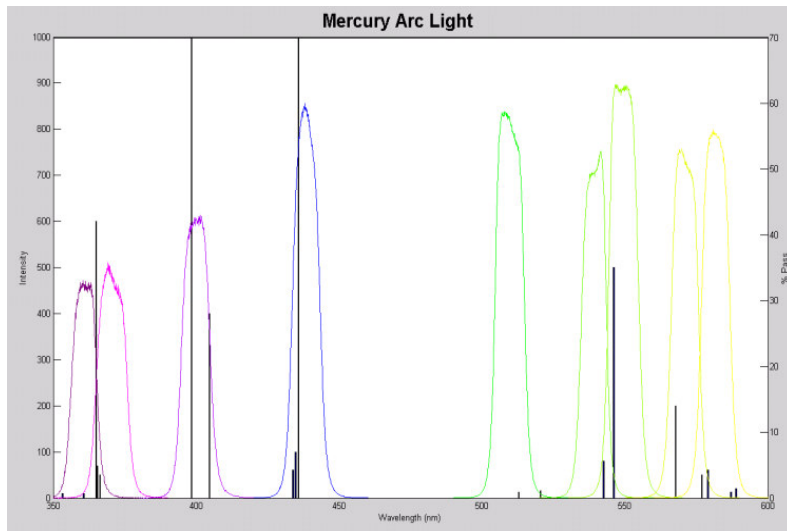
Device A Failure Conditions 52.8V, 1.6W

V_G (0V)	V_{DS} (~53V)	I_D (~30mA)	V_{GD} (~53V)
0V	~17.25V	~93mA	~17.25V
-1V	~24.5V	~65.3mA	~25.5V

Device B Failure Conditions 48.7V, 1.4W

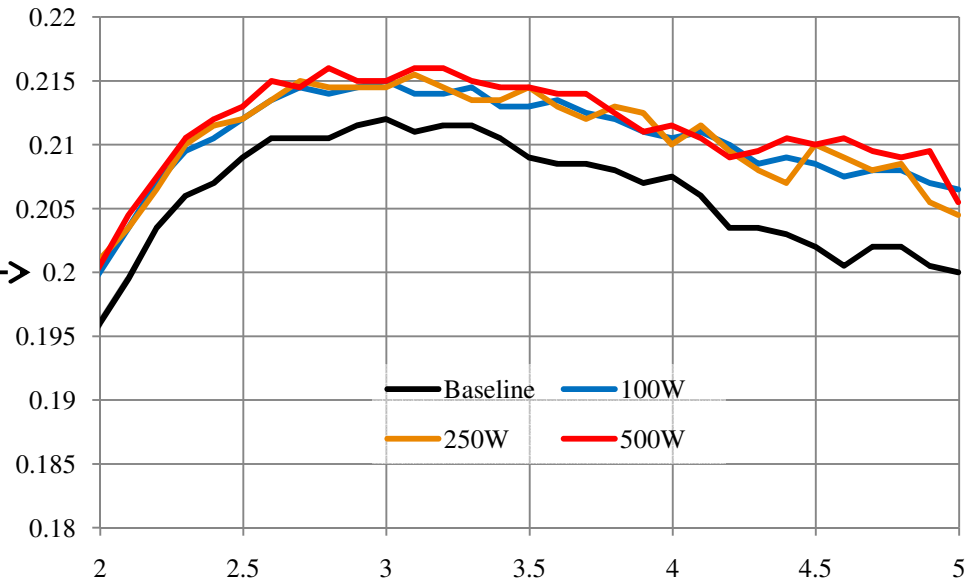
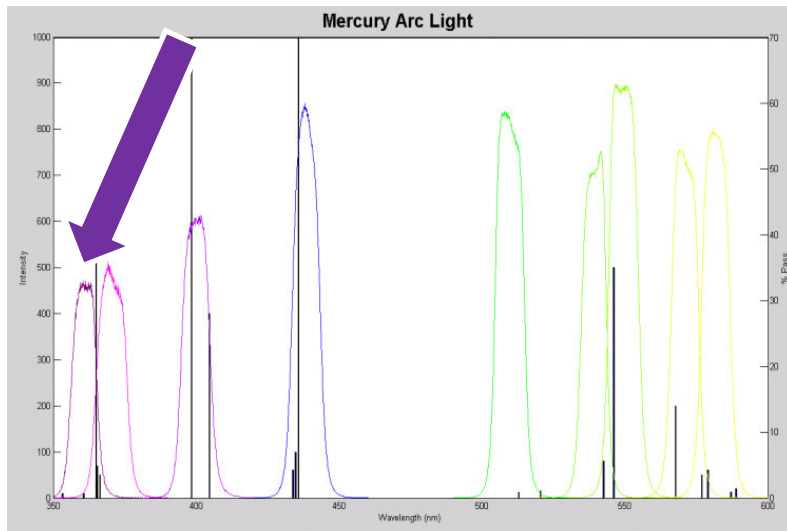
V_G (0V)	V_{DS} (~48.7V)	I_D (~28.9mA)	V_{GD} (~48.5V)
0V	~15V	~93.33mA	~15V
-1V	~20.75V	~67.5mA	~21.75V

AFRL Parts

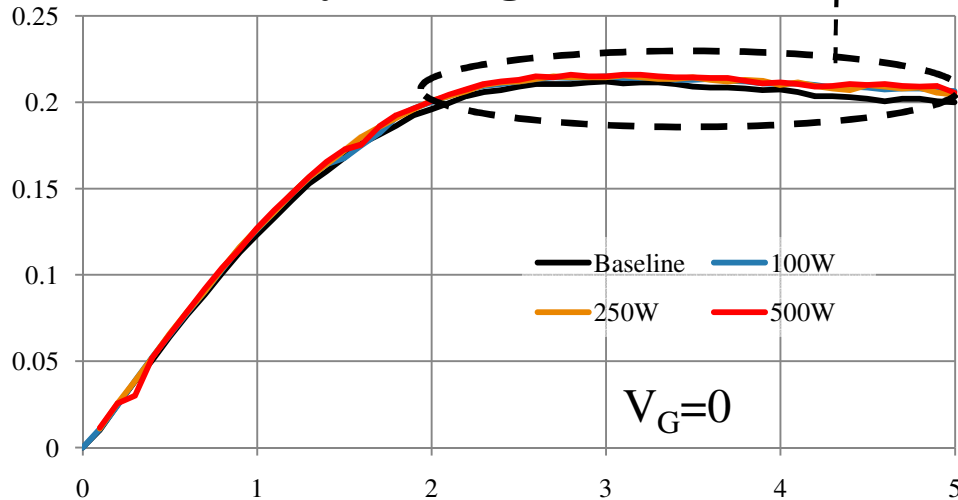


- ~2.5% Increase @ 100W
- @Higher power levels gains offset by IR heating

AFRL Parts

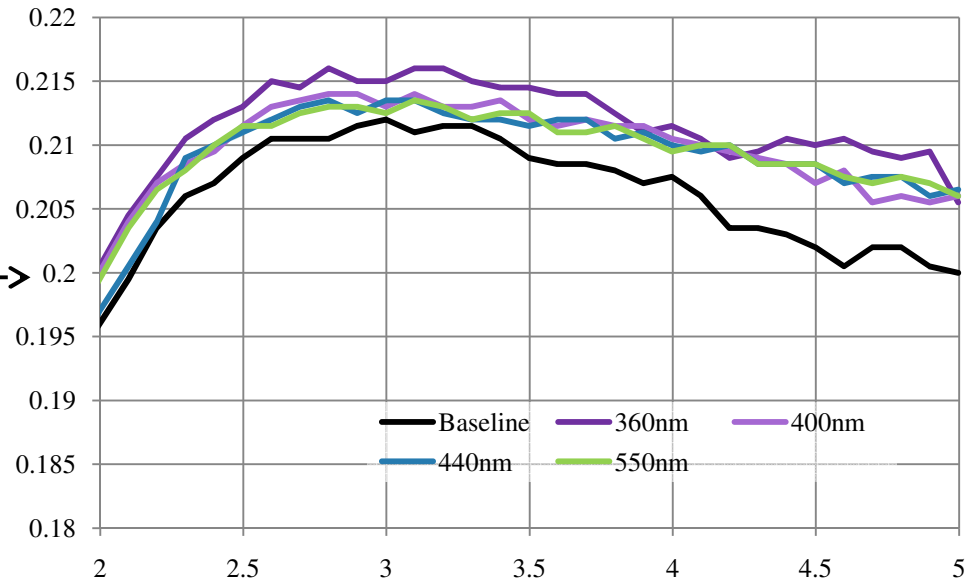
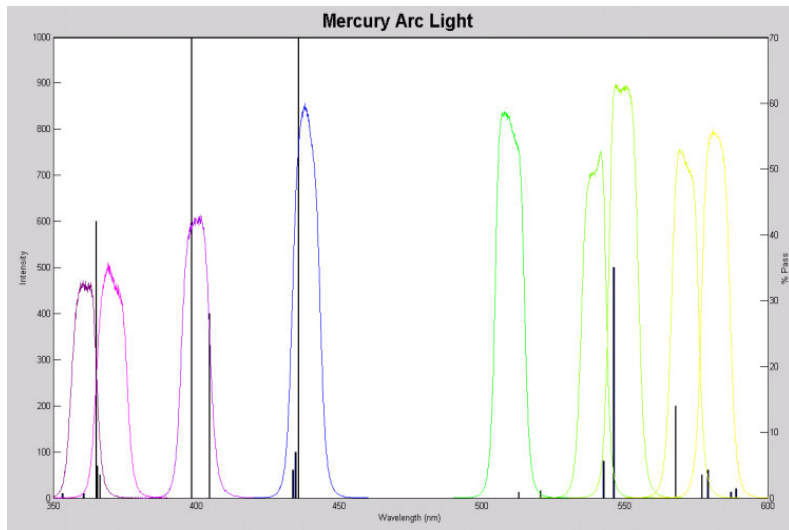


Mercury Arc Light 360nm Filter

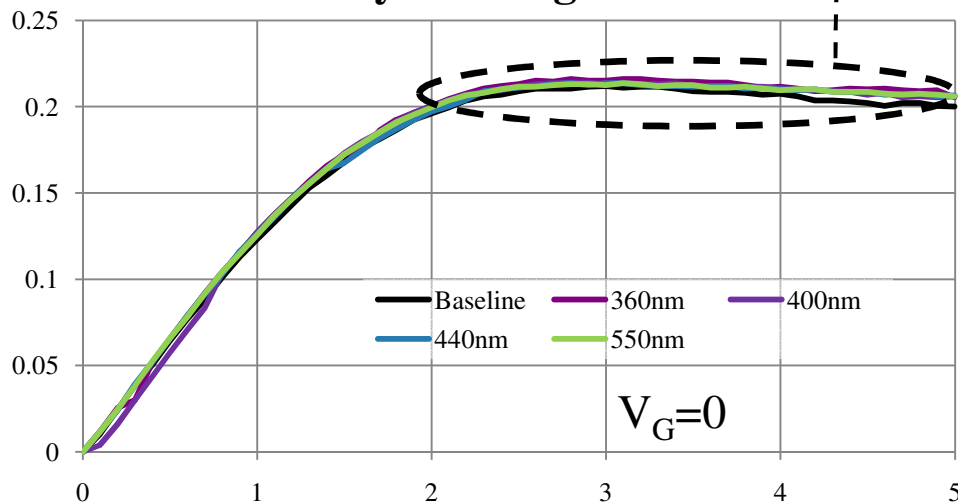


- No IR heating
- Fe Doping?
- Fewer traps?

AFRL Parts



Mercury Arc Light Filtered



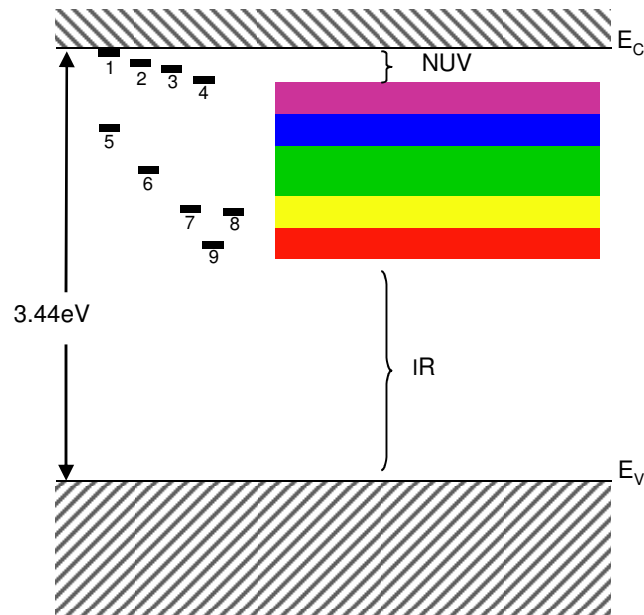
- Shorter wavelength (360nm) clears more traps.

FUTURE WORK

- Light Intensity
- Dependence on device structure, dopants, and passivation.
- Recovery Rate
 - Other factors besides time: dopants, growth processes, and passivation

FUTURE WORK

- Light Wavelength
 - Detection of different line and point defects



Defect	eV	Defect Type
1	3.41	basal plane stacking faults on polar GaN basal plane stacking faults on non-polar GaN a-type threading dislocations
2	3.34	a-plane stacking faults
3	3.28	partial dislocations
4	3.20	C_N
5	2.9	Blue defect - O_N , dopants
6	2.5	Green defect - $V_{Ga}O_N$, dopants
7	2.2	Yellow defect - several vacancy defect models, V_{Ga} bound to dislocation, dopants
8	2.21	edge dislocations (screw dislocations are invisible)
9	1.8	Red defect - $V_N C_N$, implant damage, dopants

SUMMARY

- Proof-of-concept
 - Optically pumping GaN HEMTs from an unfiltered mercury arc lamp
 - An order of magnitude increase in the drain current
- To Failure Comparison to Unexposed Devices
 - $3\times I_D$ at $1/3$ the V_{DS} and V_{DG}
- AFRL Parts
 - 2.5% I_D Increase
 - Fewer traps?
 - Fe Doping?